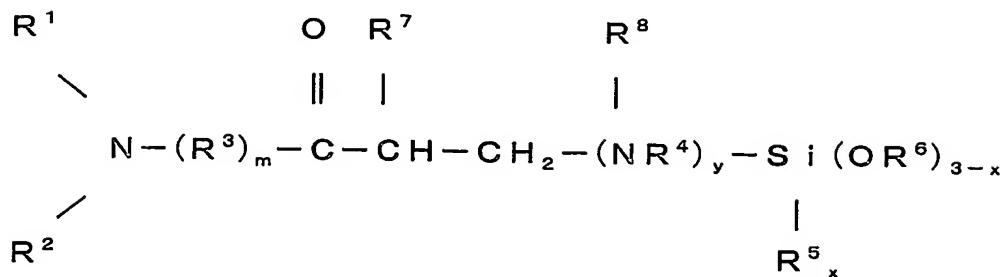


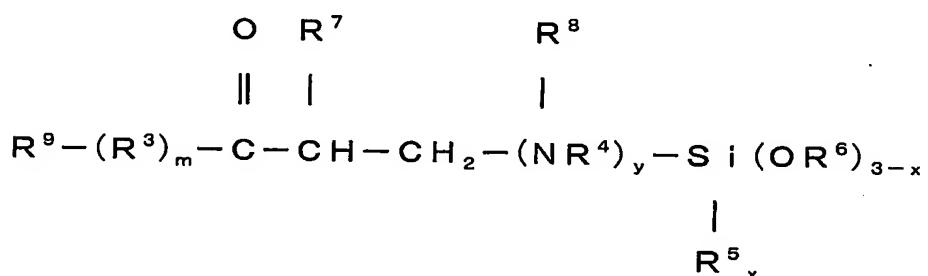
CLAIMS

1. A nitrogen-containing organosilicon compound of the formula:



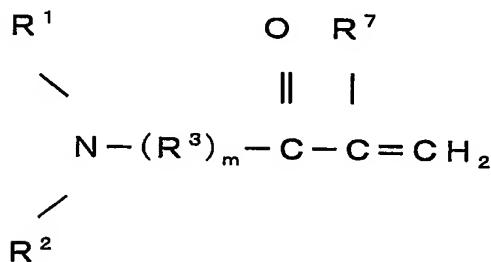
5 wherein R¹ and R² are the same or different univalent hydrocarbon groups with 1-15 carbon atoms; R³ is a bivalent hydrocarbon group with 1-15 carbon atoms, or an alkyleneoxy group of the formula -C_nH_{2n}O- where n is 1-15; R⁴ is a bivalent hydrocarbon group with 1-15 carbon atoms; R⁵ is a univalent hydrocarbon group with 1-15 carbon atoms; R⁶ is a univalent hydrocarbon group with 1-15 carbon atoms or an 10 alkoxyalkyl group; R⁷ is an alkyl group or a hydrogen atom; R⁸ is a hydrogen atom, an alkyl group with 1-20 carbon atoms, or an aryl group; m is 0 or 1; x is 0-2; and y is 1-5.

2. A nitrogen-containing organosilicon compound of the formula:

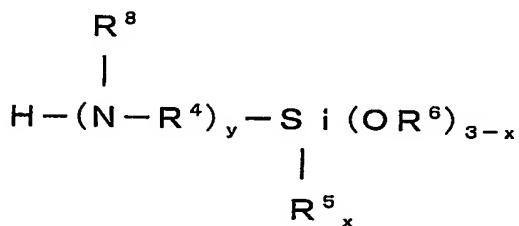


wherein R⁹ is an alicyclic amino group or a heterocyclic amino group containing 1-4 nitrogen atoms, 3-17 carbon atoms, 0-2 oxygen atoms, and 4-34 hydrogen atoms; R³ is a bivalent hydrocarbon group with 1-15 carbon atoms, or an alkyleneoxy group of the formula -C_nH_{2n}O- where n is 1-15; R⁴ is a bivalent hydrocarbon group with 1-15 carbon atoms; R⁵ is a univalent hydrocarbon group with 1-15 carbon atoms; R⁶ is a univalent hydrocarbon group with 1-15 carbon atoms or an alkoxyalkyl group; R⁷ is an alkyl group or a hydrogen atom; R⁸ is a hydrogen atom, an alkyl group with 1-20 carbon atoms, or an aryl group; m is 0 or 1; x is 0-2; and y is 1-5.

10 3. A method of manufacturing a nitrogen-containing organosilicon compound comprising the addition reaction of a compound of the formula;



and a compound of the formula:



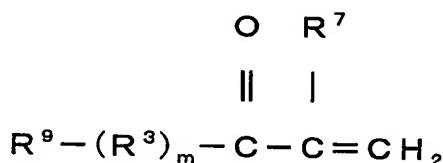
15 wherein R¹ and R² are the same or different univalent hydrocarbon groups with 1-15 carbon atoms; R³ is a bivalent hydrocarbon group with 1-15 carbon atoms, or an

alkyleneoxy group of the formula $-C_nH_{2n}O-$ where n is 1-15; R^4 is a bivalent hydrocarbon group with 1-15 carbon atoms; R^5 is a univalent hydrocarbon group with 1-15 carbon atoms; R^6 is a univalent hydrocarbon group with 1-15 carbon atoms or an alkoxyalkyl group; R^7 is an alkyl group or a hydrogen atom; R^8 is a hydrogen atom, an alkyl group with 1-20 carbon atoms, or an aryl group; m is 0 or 1; x is 0-2; and y is 1-5.

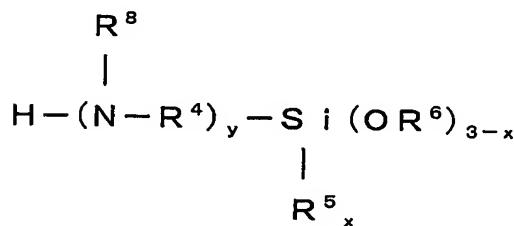
4. A method of manufacturing the nitrogen-containing organosilicon compound defined in

Claim 1 according to Claim 3.

10 5. A method of manufacturing a nitrogen-containing organosilicon compound comprising the addition reaction of a compound of the formula:



and a compound of the formula:



15 wherein R^9 is an alicyclic amino group or a heterocyclic amino group containing 1-4 nitrogen atoms, 3-17 carbon atoms, 0-2 oxygen atoms, and 4-34 hydrogen atoms; R^3 is a bivalent hydrocarbon group with 1-15 carbon atoms, or an alkyleneoxy group of the formula $-C_nH_{2n}O-$ where n is 1-15; R^4 is a bivalent hydrocarbon group with 1-15

carbon atoms; R⁵ is a univalent hydrocarbon group with 1-15 carbon atoms; R⁶ is a univalent hydrocarbon group with 1-15 carbon atoms or an alkoxyalkyl group; R⁷ is an alkyl group or a hydrogen atom; R⁸ is a hydrogen atom, an alkyl group with 1-20 carbon atoms, or an aryl group; m is 0 or 1; x is 0-2; and y is 1-5.

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6. A method of manufacturing the nitrogen-containing organosilicon compound defined in Claim 2 according to Claim 5.

10 7. A method of treating surfaces comprising applying to the surfaces a nitrogen-containing organosilicon compound according to Claim 1.

8. A method of treating surfaces comprising applying to the surfaces a nitrogen-containing organosilicon compound according to Claim 2.

15 9. A method of treating surfaces comprising applying to the surfaces a solution containing the nitrogen-containing organosilicon compound according to Claim 1.

10. A method of treating surfaces comprising applying to the surfaces a solution containing the nitrogen-containing organosilicon compound according to Claim 2.

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